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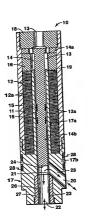
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(54) Title: SLURRY TOLERANT PILOT OPERATED RELIEF VALVE

(57) Abstract: Cartridge-style fluid control devices are provided that are static pressure independent and capable of repeatable, reliable, particulate insensitive performance in service conditions typical of downhole intervention environments.



GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SL, KK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, MJ, MR, NE, SN, TD, TG).

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